

Comparison of the same Mo coating on different substrates by SEM. Effect on the resistivity

Jorge Guardia-Valenzuela (EN-MME-EDS)

HiCoIDEM meeting 30-08-2018

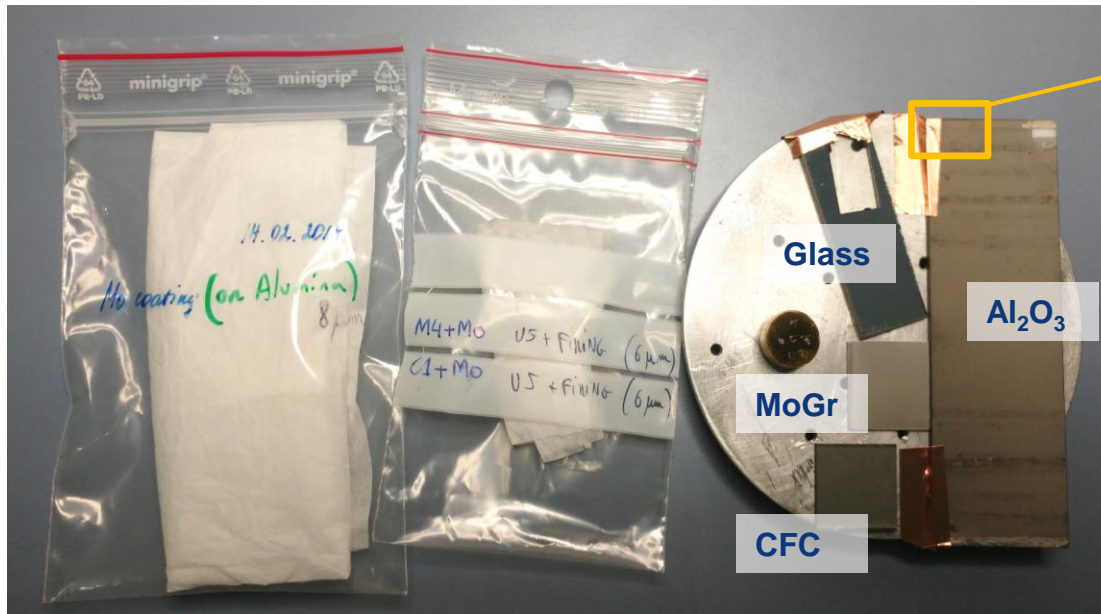


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Observed specimens (SEM)

Four samples observed, Mo on:

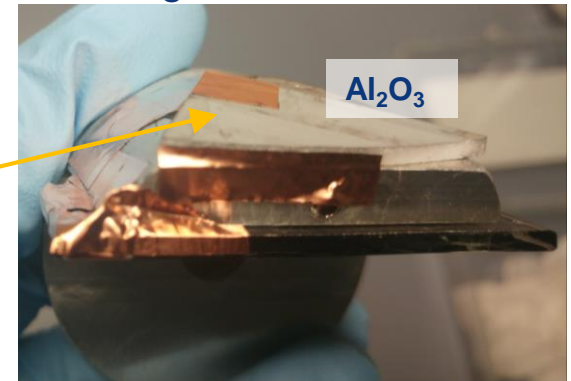
- Glass
- Alumina
- MoGr NA-8304Gb
- CFC FS140 2800°C



Observations 8-Aug-2018

MoGr substrate observed on September 2017: Grade MG-6403Fc

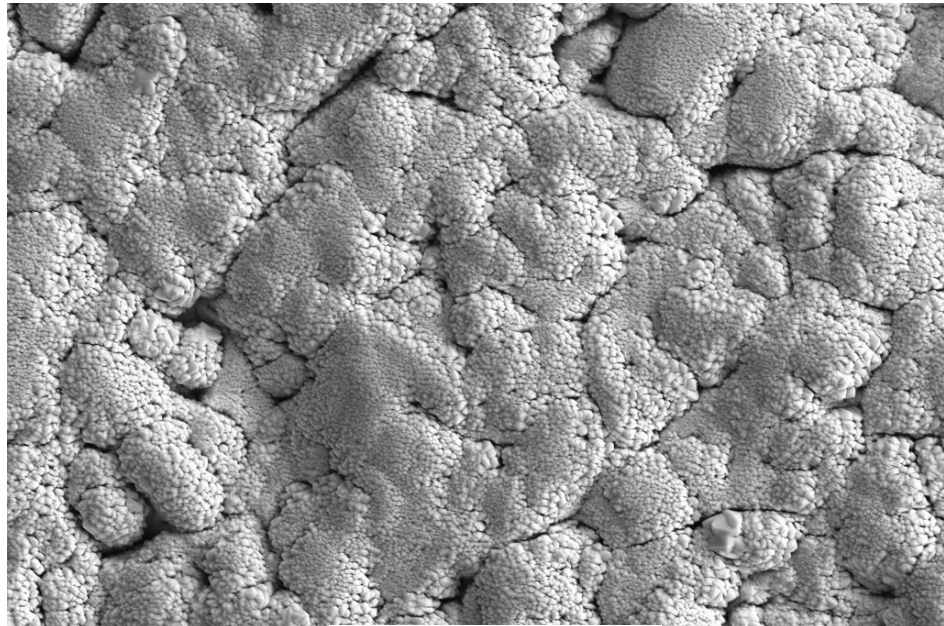
Coating fracture surfaces



Observations 14-Aug-2018

Comparison all substrates

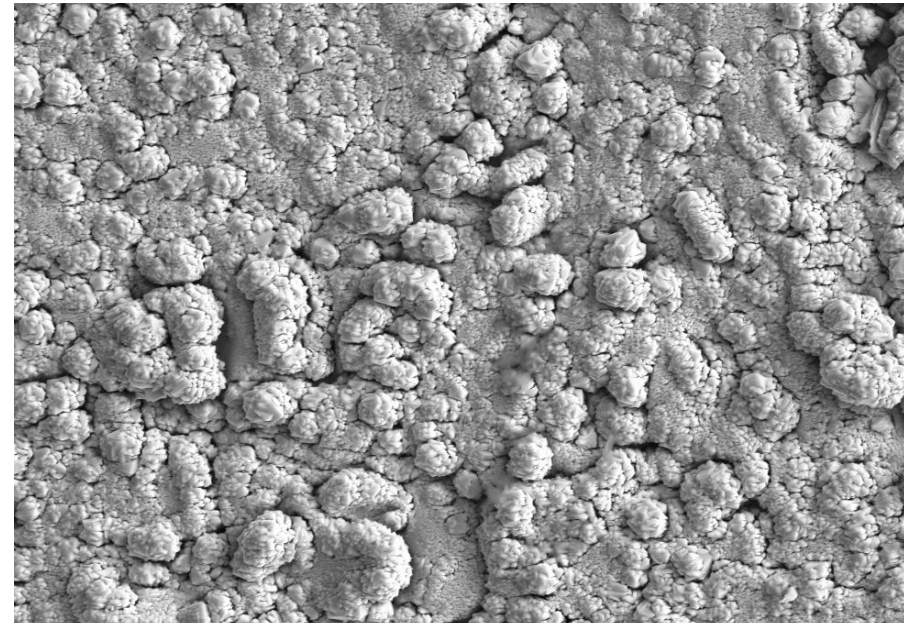
Top-view comparison. Same scale



10 μ m
EHT = 20.00 kV
WD = 10.5 mm
Signal A = SE2

Mo on Al₂O₃

Date :8 Aug 2018
Mag = 3.00 K X
Jorge Guardia



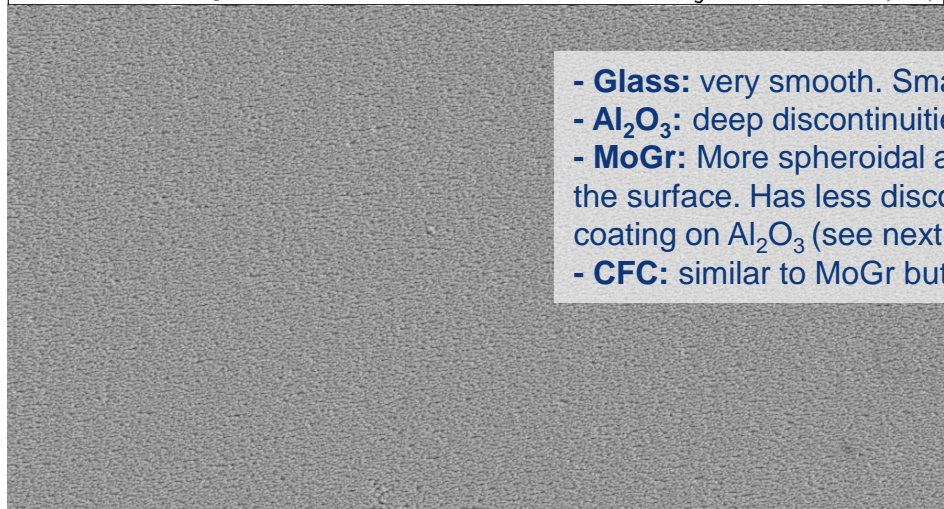
10 μ m
EHT = 20.00 kV
WD = 10.5 mm
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Mo on MoGr

Date :8 Aug 2018
Mag = 3.00 K X
Jorge Guardia



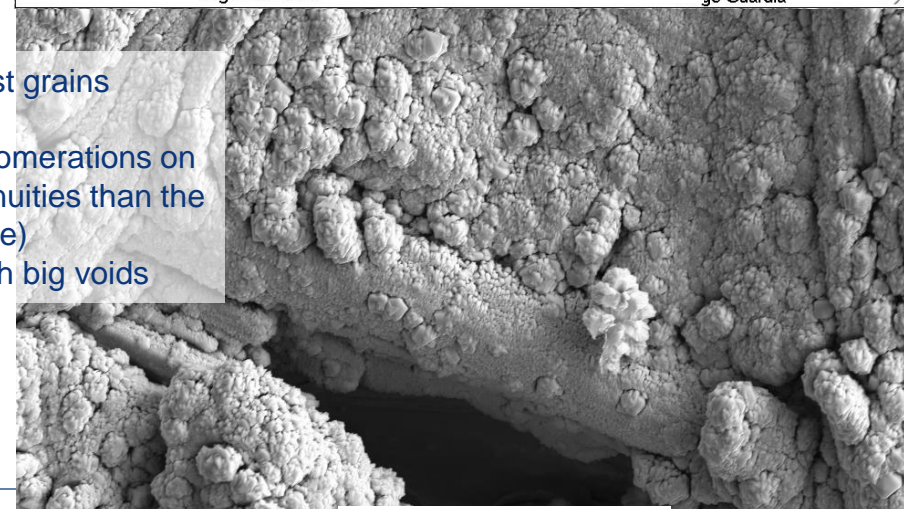
- **Glass**: very smooth. Smallest grains
- **Al₂O₃**: deep discontinuities
- **MoGr**: More spheroidal agglomerations on the surface. Has less discontinuities than the coating on Al₂O₃ (see next slide)
- **CFC**: similar to MoGr but with big voids



10 μ m
EHT = 20.00 kV
WD = 9.9 mm
Signal A = SE2

Mo on glass

Date :8 Aug 2018
Mag = 3.00 K X
Jorge Guardia



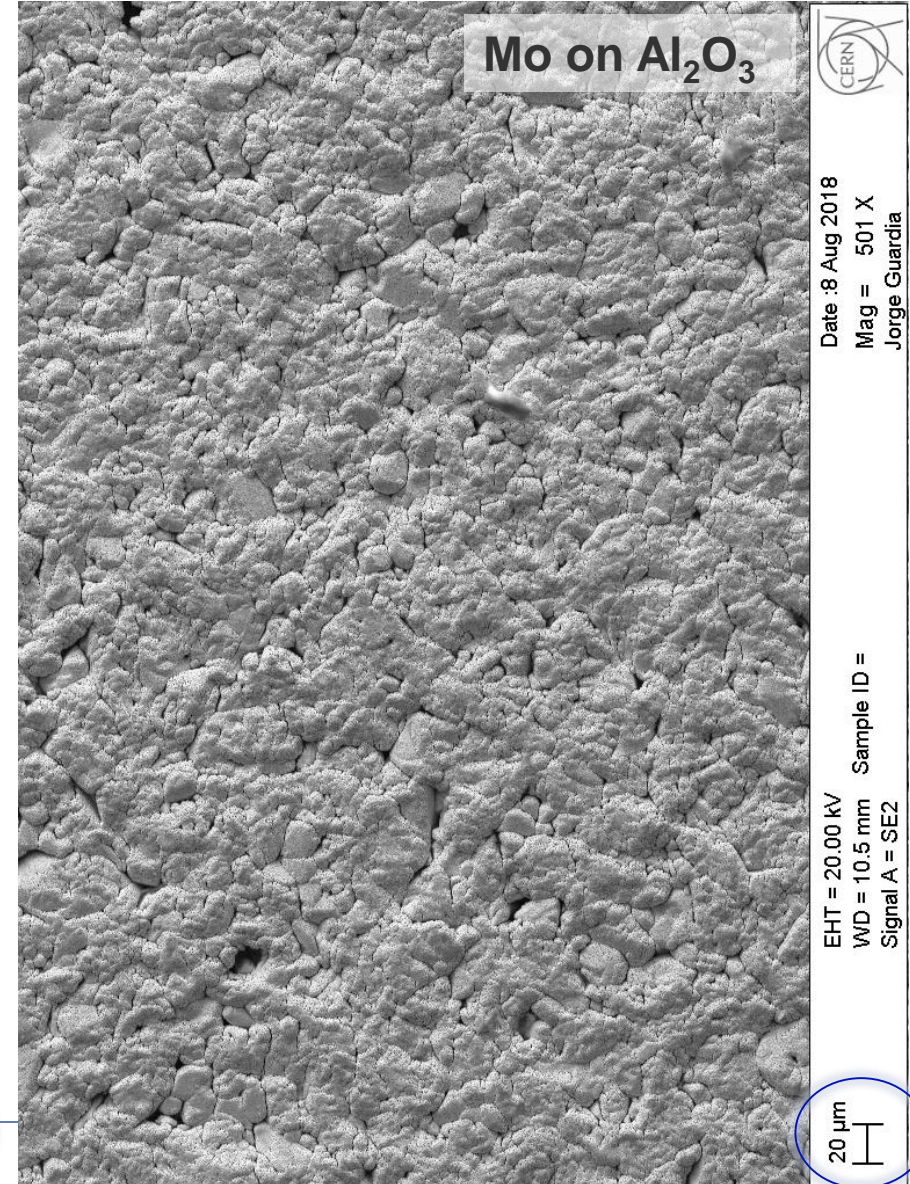
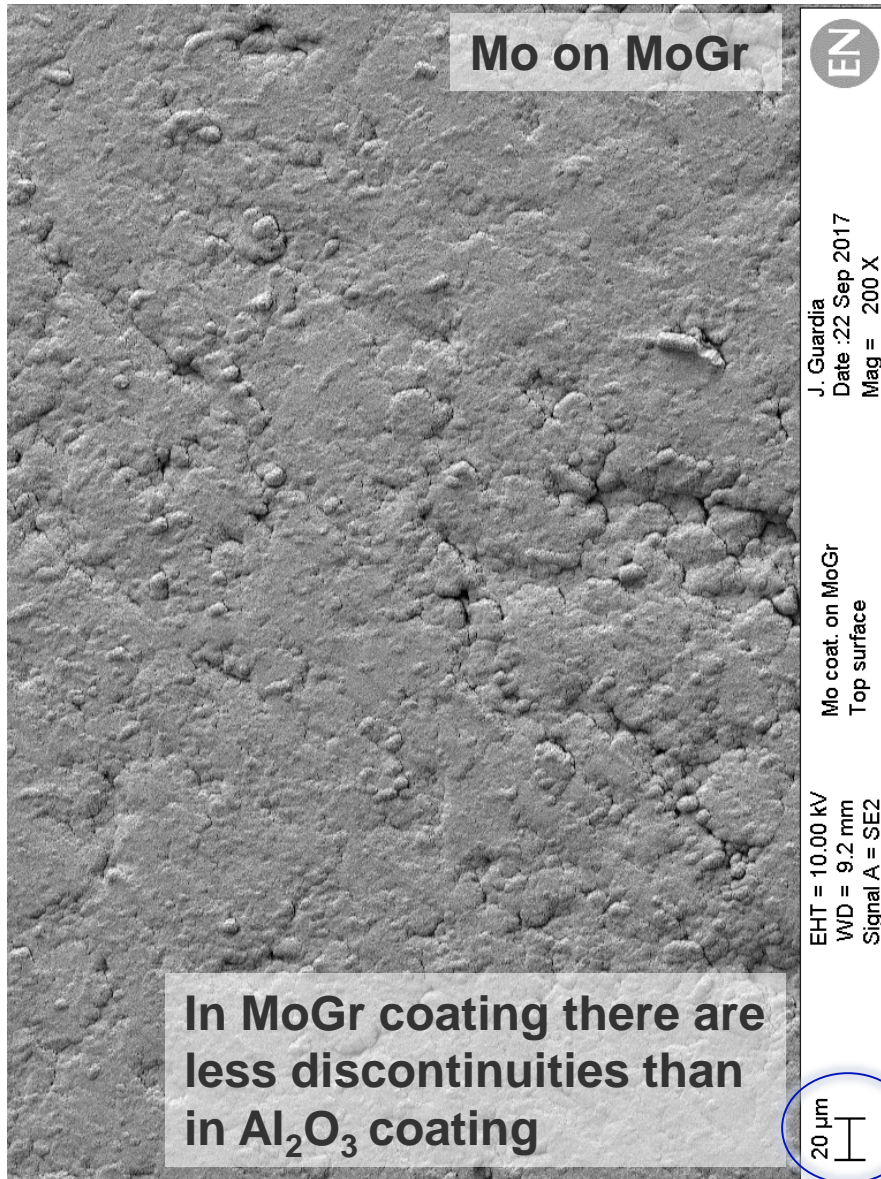
10 μ m
EHT = 20.00 kV
WD = 9.9 mm
Signal A = SE2

Mo on CFC

Date :8 Aug 2018
Mag = 3.00 K X
Jorge Guardia

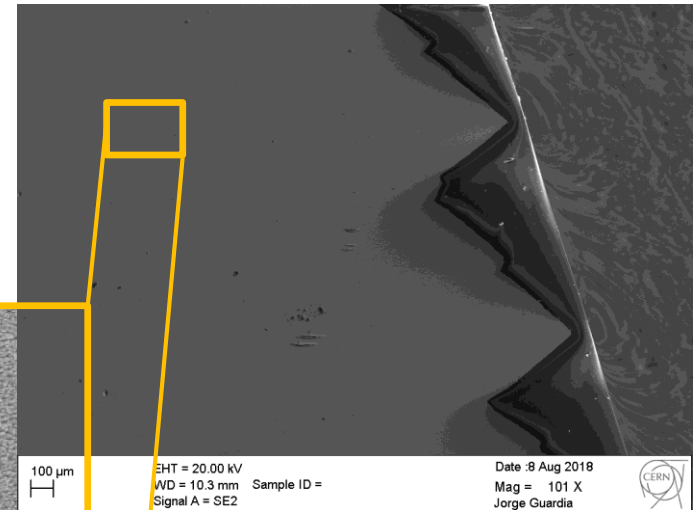
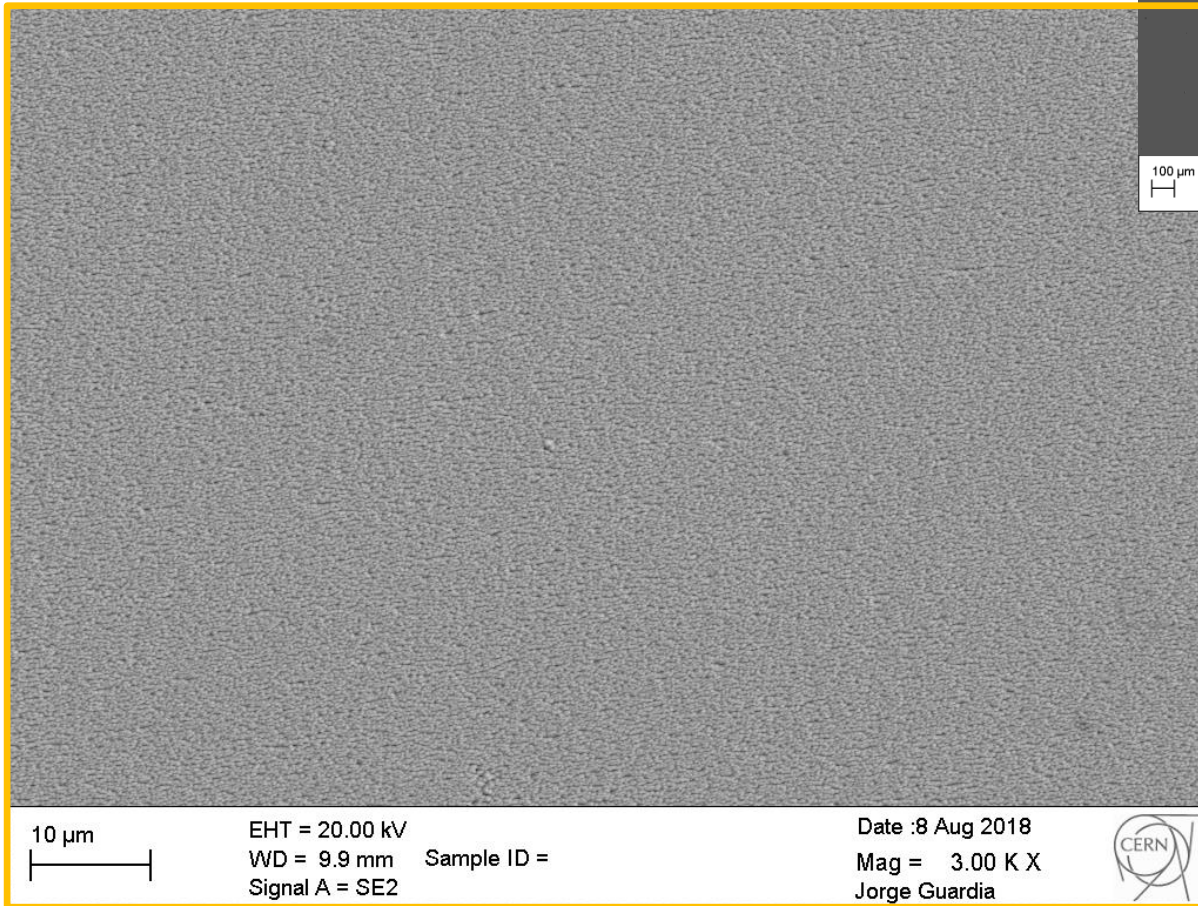


Comparison MoGr- Al_2O_3 substrates. Same scale

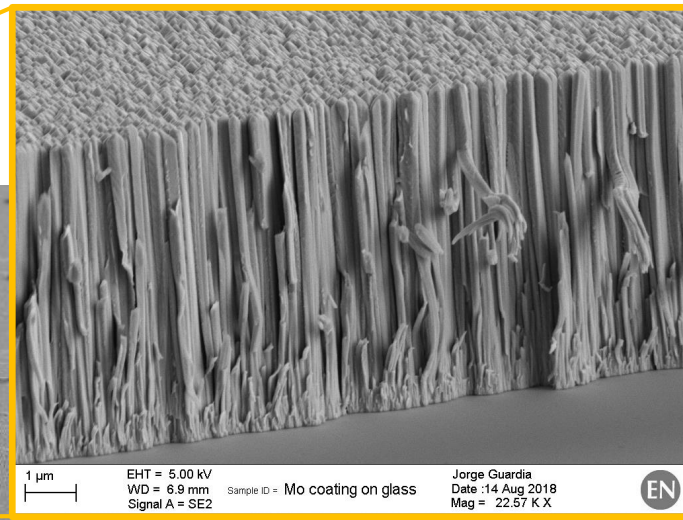
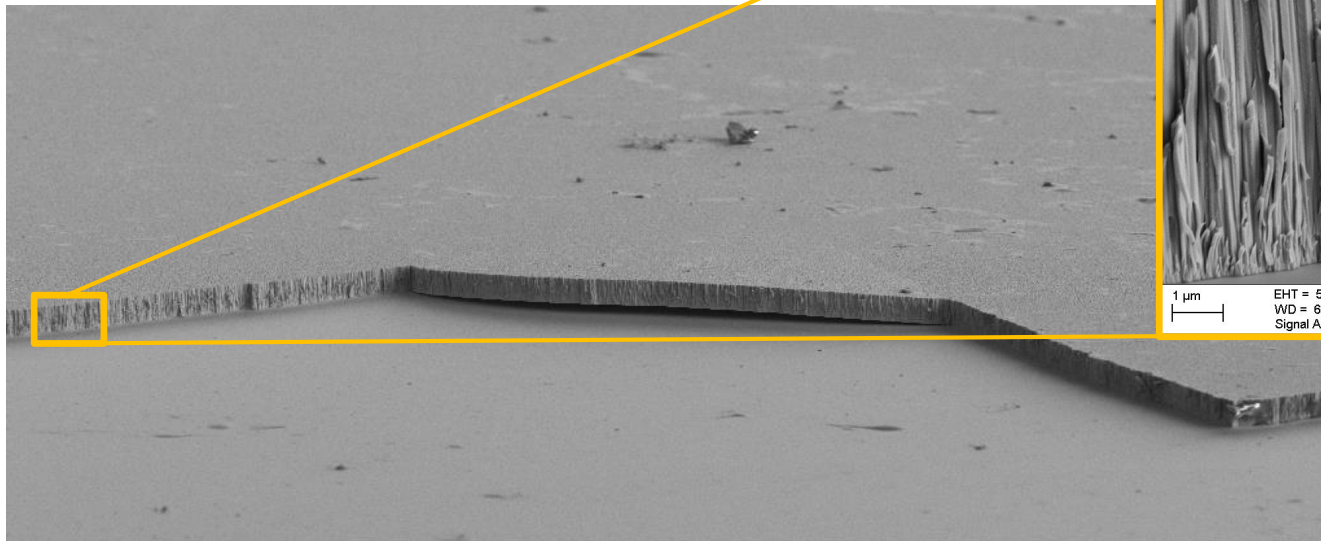


Mo on Glass

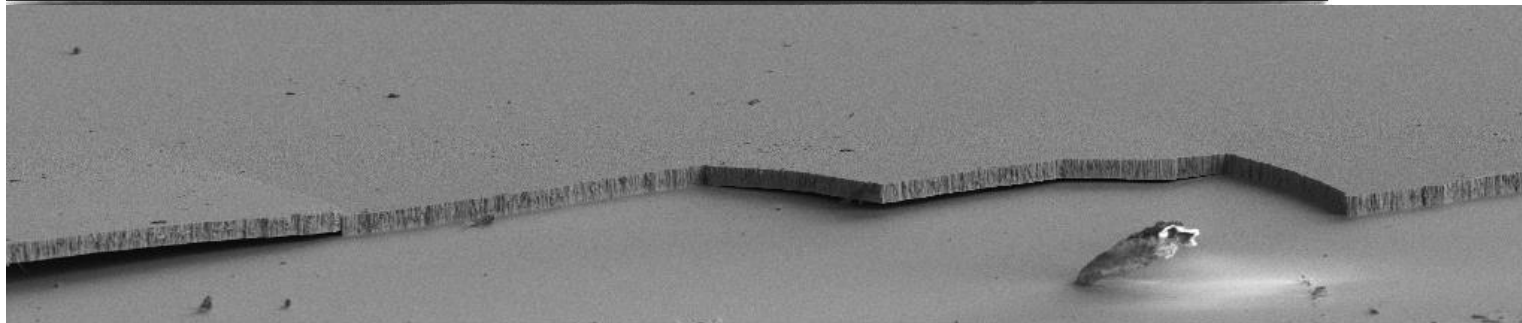
Mo on Glass



Mo on Glass

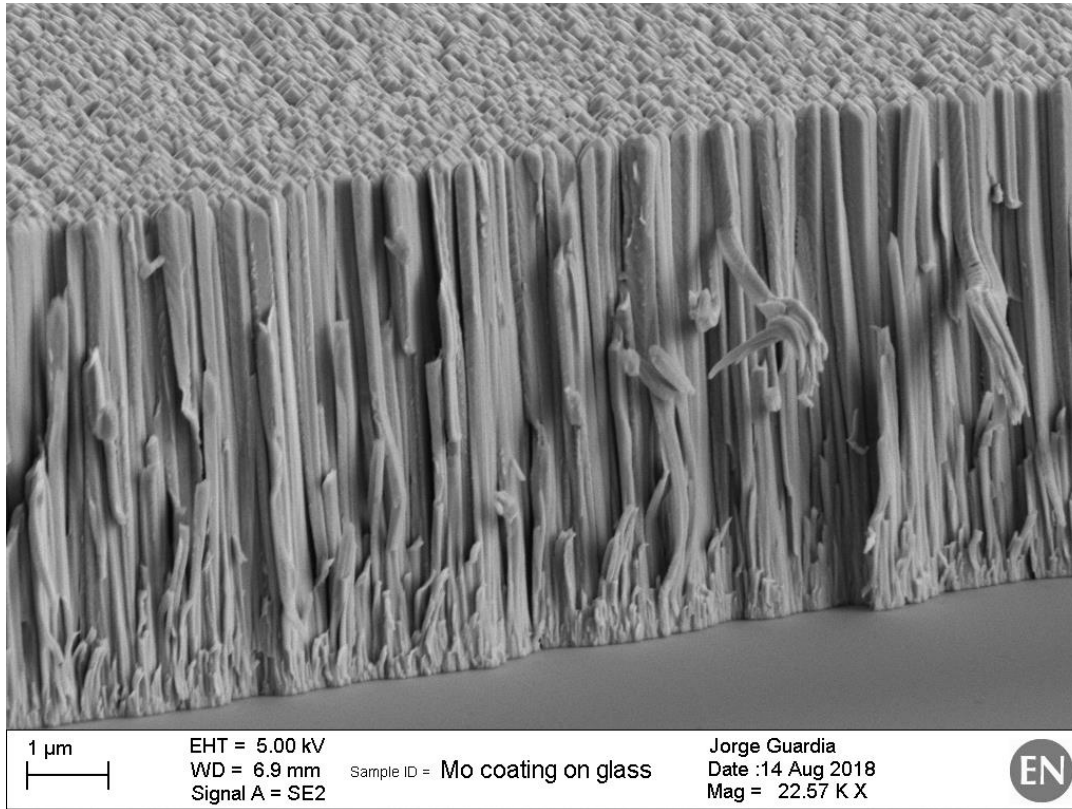


20 μm | EHT = 5.00 kV | Jorge Guardia
WD = 6.9 mm | Sample ID = Mo coating on glass | Date :14 Aug 2018
Signal A = SE2 | Mag = 967 X | EN



20 μm | EHT = 5.00 kV | Jorge Guardia
WD = 7.0 mm | Sample ID = Mo coating on glass | Date :14 Aug 2018
Signal A = SE2 | Mag = 626 X | EN

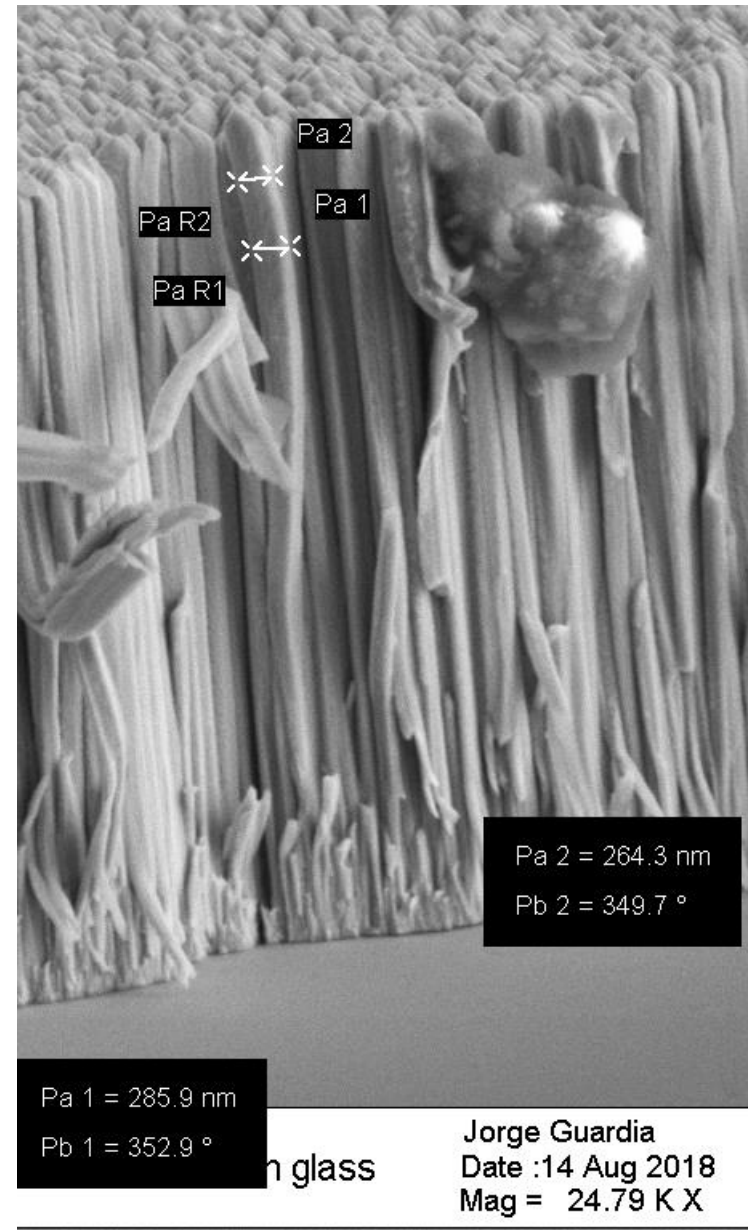
Mo on glass



The measured grain has a maximum lateral size of 286nm (close to the surface). This smaller than on the other substrates

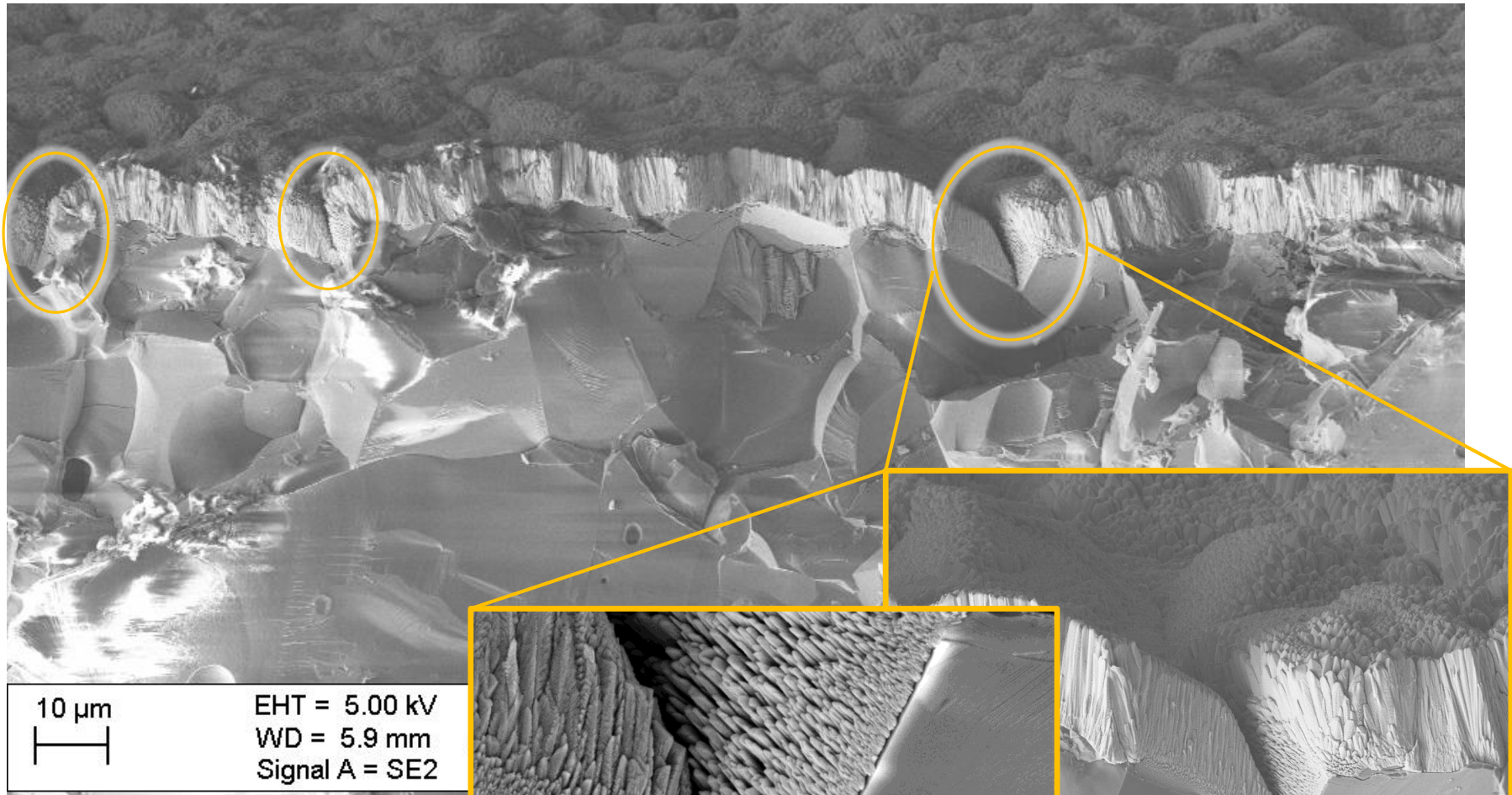
The average thickness of the coating on glass was 6.05μm. This value matches the expected one (6μm).

The bottom area of the coating shows even smaller grains → changes in resistivity depending on the height. This happens in all substrates (nucleation of grains)

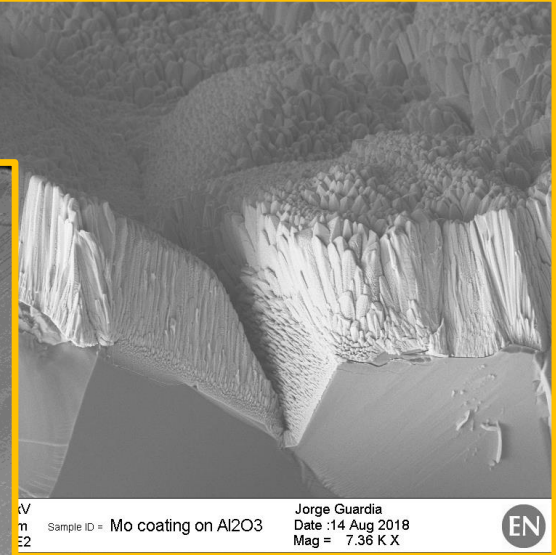
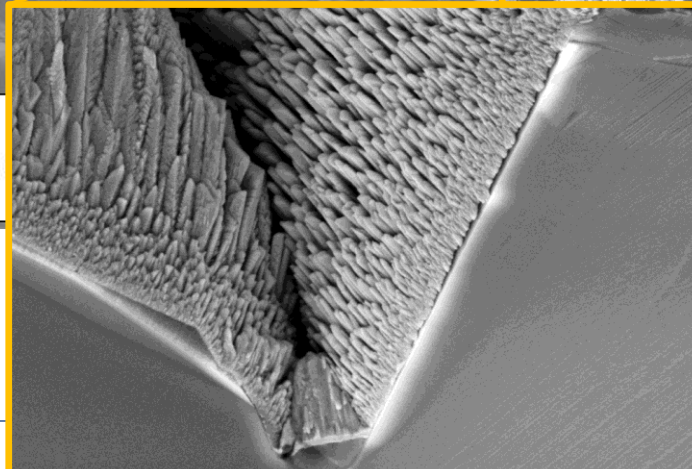


Mo on alumina

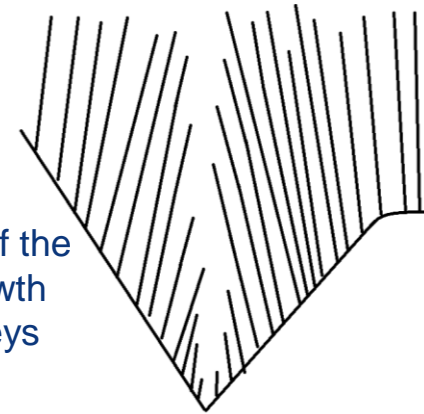
Mo on Alumina fracture surface



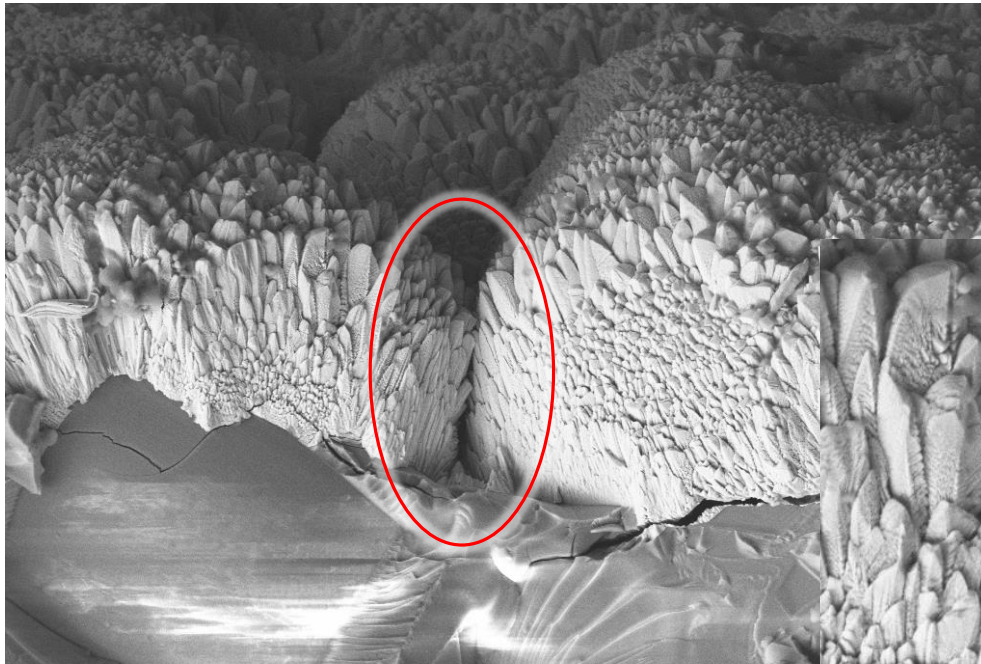
Discontinuities



Mo on Alumina fracture surface. Discontinuities



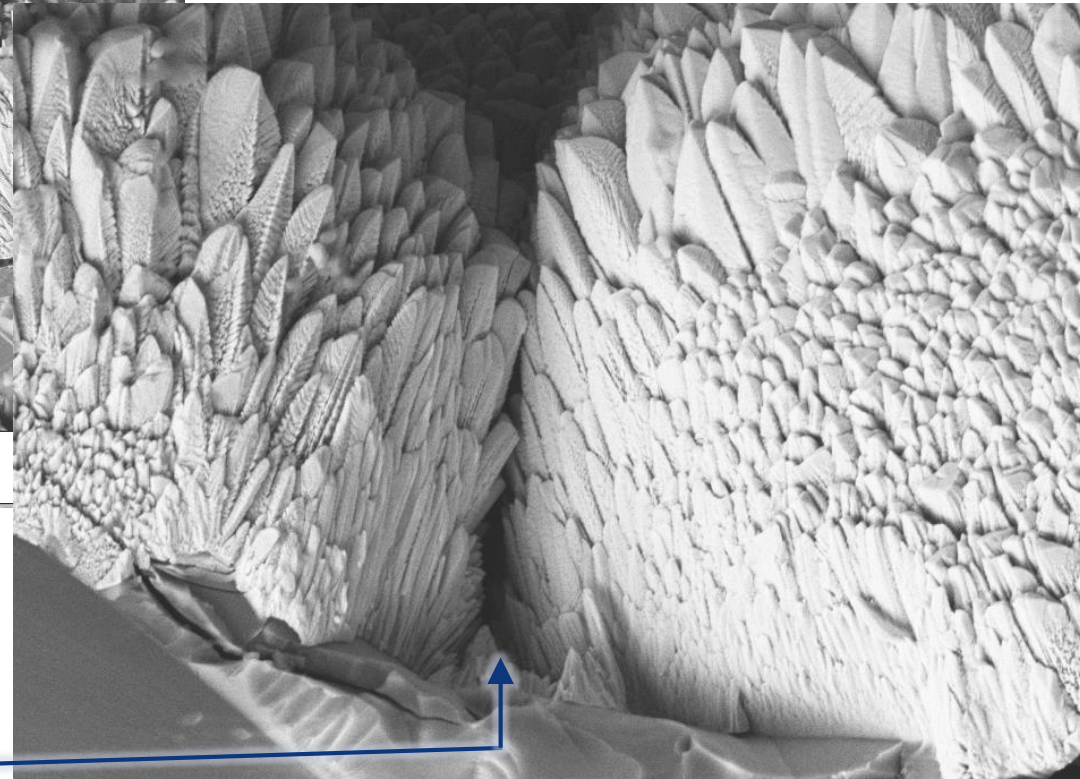
Schematic of the thin-film growth in deep valleys



2 μ m EHT = 5.00 kV
WD = 5.6 mm Signal A = SE2 Sample ID = Mo coating on Al₂O₃ Jorge Guardia
Date :14 Aug 2018
Mag = 8.24 K X

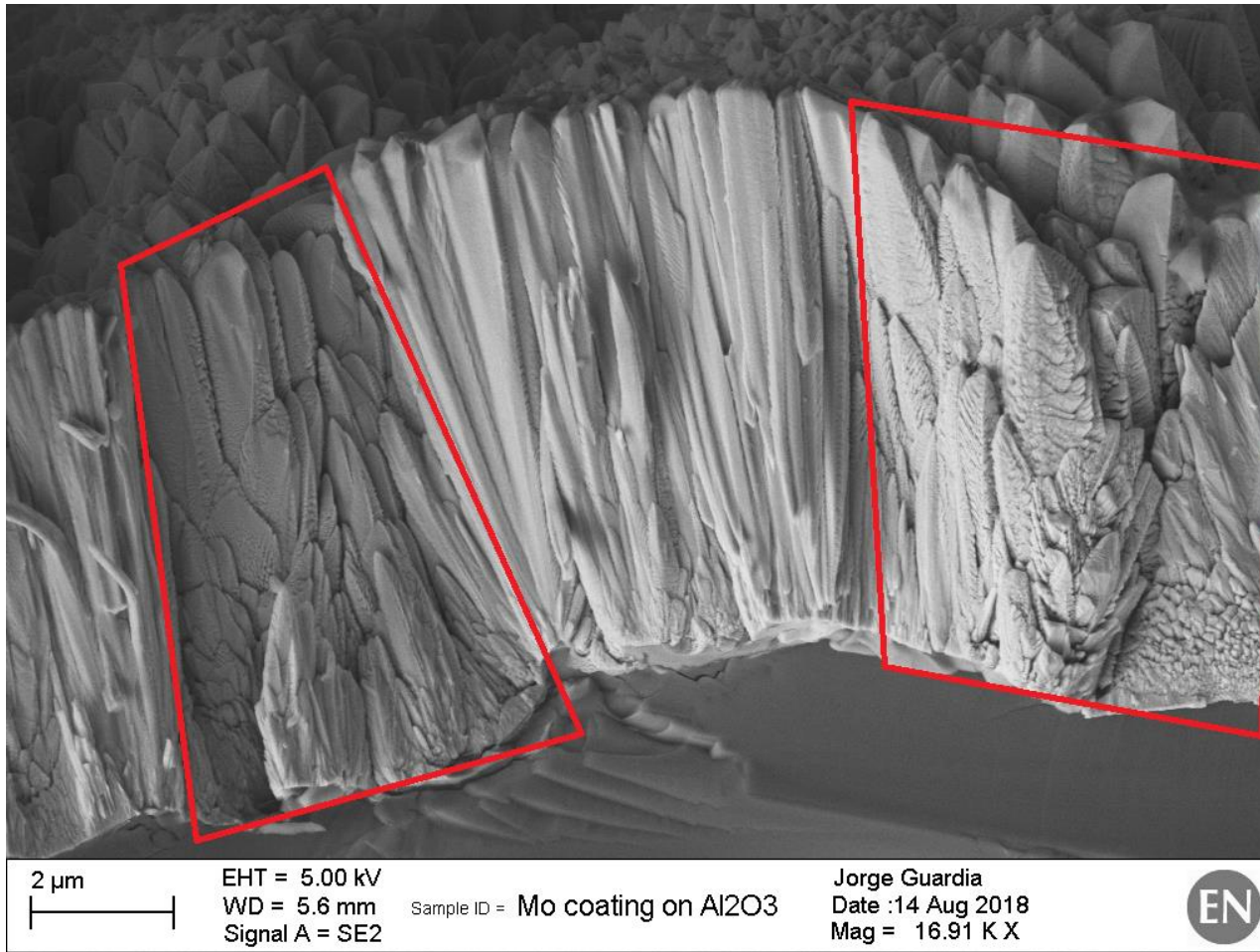
In deep valleys, the grains have irregular growing speed (shadowed deposition), forming a stair of grains with different heights that creates a discontinuity.

Bad contact



2 μ m EHT = 5.00 kV
WD = 5.6 mm Signal A = SE2 Sample ID = Mo coating on Al₂O₃ Jorge Guardia
Date :14 Aug 2018
Mag = 17.98 K X

Mo on Alumina fracture surface

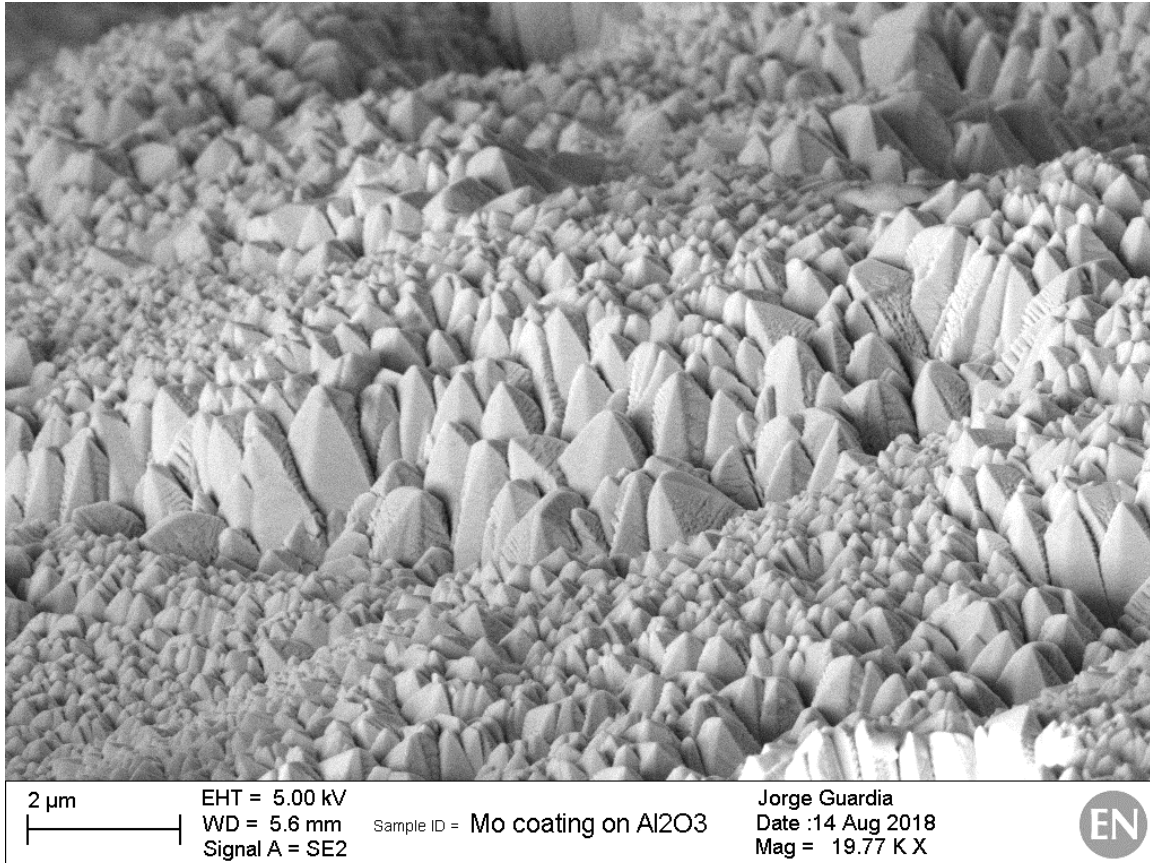


Areas with that kind of stairs of grains with different heights are visible in the fracture surface (in red).

This is because the discontinuity is a weak point and the fracture developed there (bad contact)

The other areas show a different morphology (intergranular fracture), showing that there was good cohesion there.

Mo on Alumina. Side view

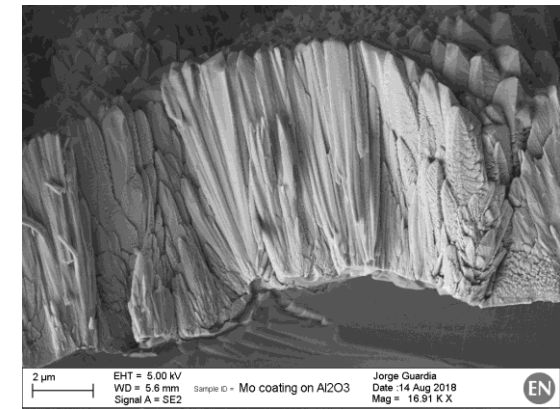
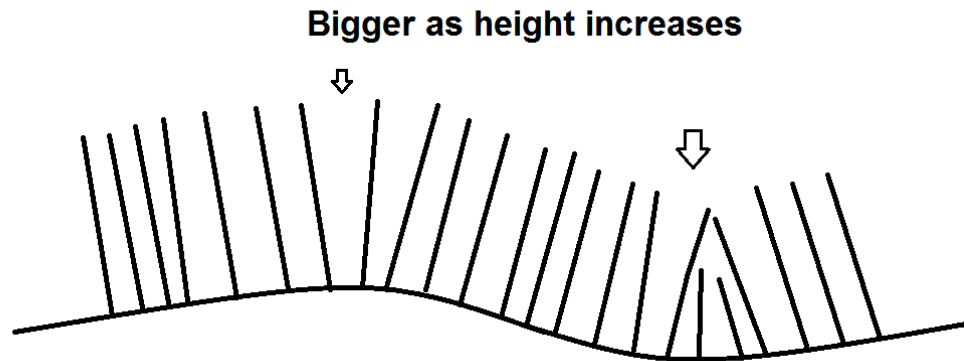


Grain (lateral) size at the surface is approximately between 0.3 and 2 μm

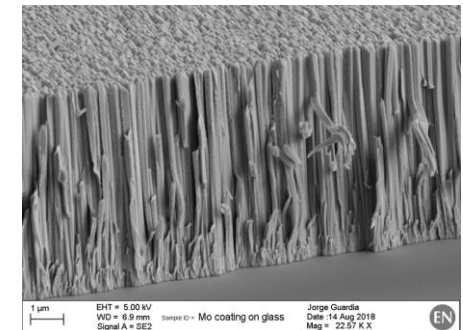
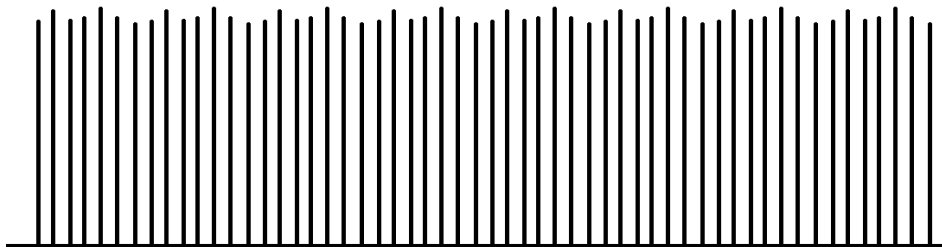
Why are there smaller grains on glass?

- Most likely, there is an effect of the roughness:

On substrates other than glass, the waves on the surface make some grains to grow more than others and block their growth, so the average grain size increases.



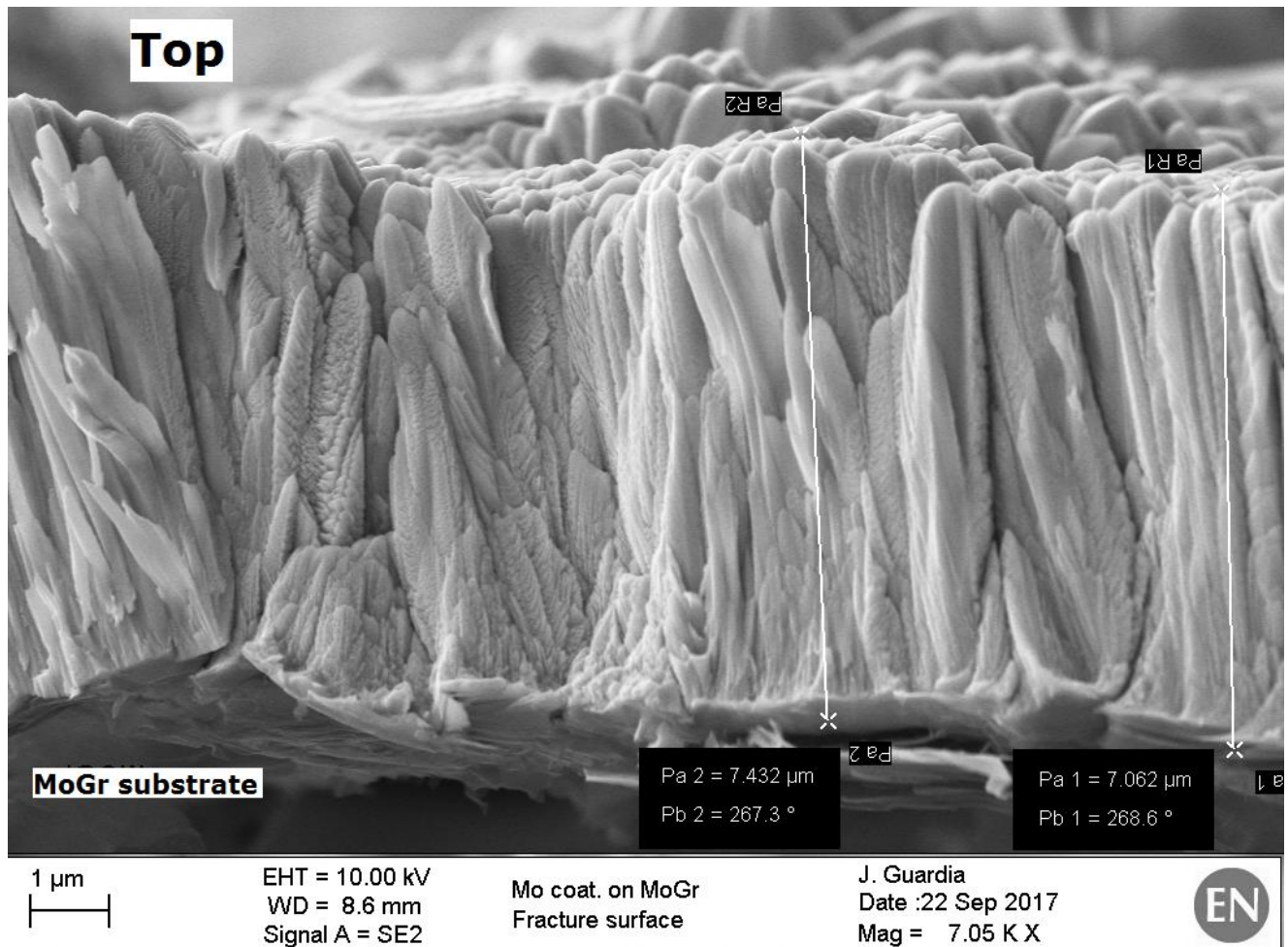
The coating on glass shows very homogeneous small grains because all are in the same geometrical conditions to grow.



Mo on MoGr

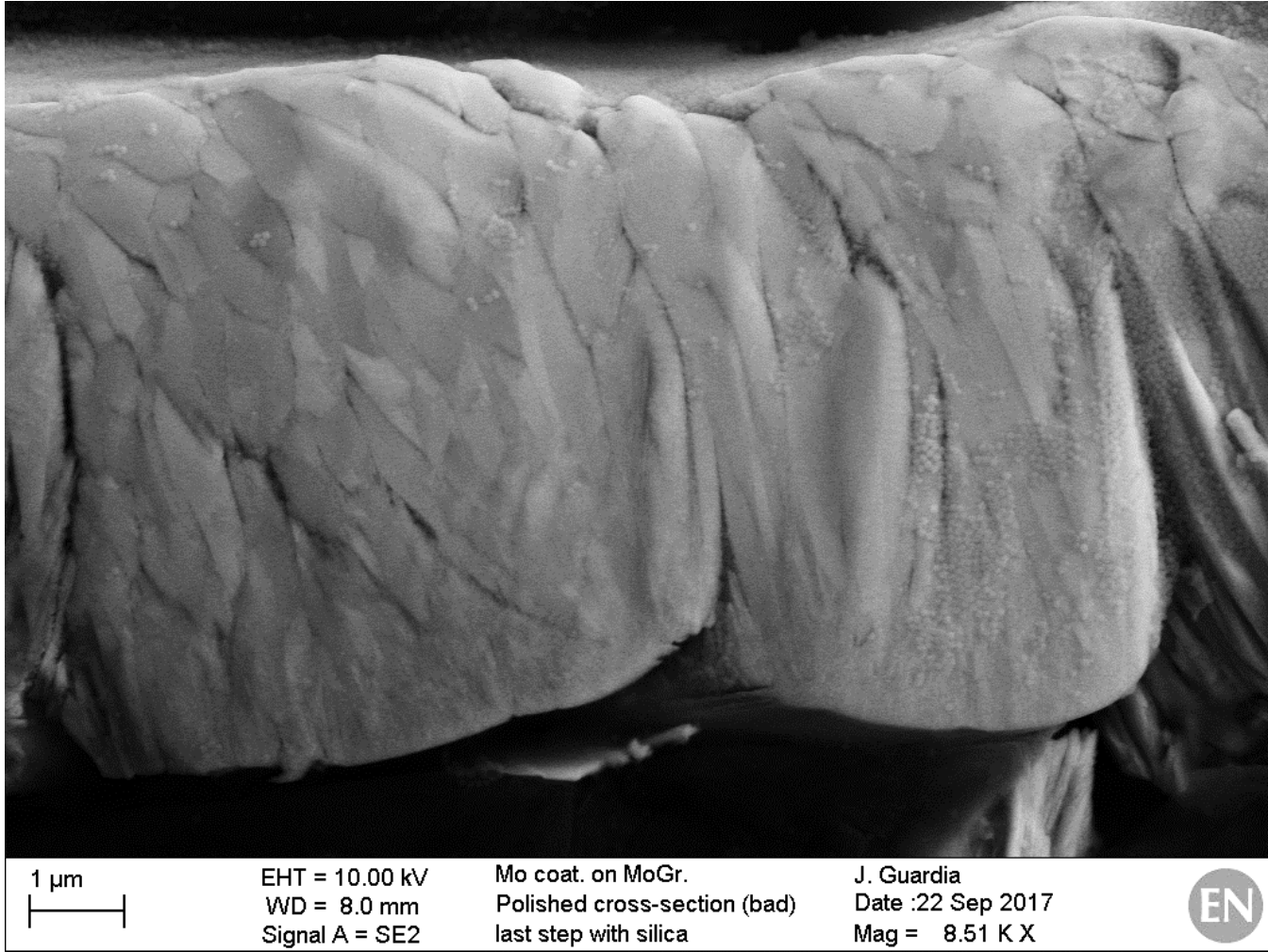
SEM of Mo coating on MoGr (Impedance meeting 20-4-2018)

<https://indico.cern.ch/event/664498/>



Grain (lateral) size close to the surface is approximately 0.5 μm

Mo on MoGr



SEM image showing contrast between different grains (polished surface, not very nice preparation). This allows clear identification of grain size and shape.

The spherical particles are silica, coming from the preparation of the sample.

Average grain size close to the top surface is approximately $0.5\mu\text{m}$, slightly bigger than on glass ($0.3\mu\text{m}$)

Alumina-MoGr differences (discontinuities)
explained by the roughness:

→ Roughness measurements of the
substrates without coating

Roughness measurements

(Impedance meeting 20-4-2018)
<https://indico.cern.ch/event/664498/>

Specimen	Surface treatment	Coating	Rq	Ra	Rt	Rz	Method X-spac
Alumina	-	-	4.1	2.9	41.6	26.7	O. 2.5µm
Alumina	-	Mo	3	2.2	38.8	23.3	O. 2.5µm
CFC C07	Mach+US	-	9.2	6.8	74.8	47.5	O. 2.5µm
CFC C07	Mach+US	Mo	9.2	7	69.1	45.2	O. 2.5µm
MoGr M03	Mach+US	-	1.1	0.7	16.4	9.1	O. 2.5µm
MoGr M03	Mach+US	Mo	0.8	0.5	8.5	5	O. 2.5µm
MoGr M04	Mach+US	-	1	0.8	11.7	6.6	O. 2.5µm
MoGr M04	Pol+US	Mo	1.1	0.7	22.3	11.6	O. 2.5µm
MG-6403Fc	Mach	-	1.9	1.5	12.0	8.8	C. ?
MG-6541Fc	Mach	-	1.8	1.4	11.0	8.9	C. ?
CFC AC150K	Mach	-	4.6	3.5	46.8	23.5	C. ?
Gr R4550	Mach	-	1.4	1.0	10.3	8.3	C. ?

Mach.=Machining Pol=polishing US=Ultrasonic cleaning
 O=Optical (non-contact) C=standard contact measurement X-spac=acquisition spacing

O → [EDMS.1966152](https://cds.cern.ch/record/1966152)

C → [EDMS.1907137](https://cds.cern.ch/record/1907137)

Conclusions

- The resistivity of the coating is affected by the combination of grain size and defects (discontinuities). This seems to explain the resistivity results

Nicolò's team
measurements

	Substrate roughness	Mo grain size (average)	Amount of coating discontinuities	Coating conductivity (MS/m)	Coating resistivity (nΩ.m)
Glass	~0	+	no	+ ☹️ 4.3 [DC] 5.0 [RF]	232 [DC] 200 [RF]
Alumina	+++	++	++	+ ☹️ 4.6 [DC] 4.1 [RF]	218 [DC] 244 [RF]
MoGr	+	++	+	+++ 😊 - 14.3-16.7 [RF]	- 60-70 [RF]
CFC	++++	++	(big voids)	- ☹️ n.d. (≈substrate)	n.d. (≈substrate)

- The discontinuities are created in the deep valleys (too rough substrate) ↘ MoGr #M04
- Too flat substrate is not good either for low resistivity → smaller grains (<300nm) and low adherence
- More comprehensive studies of grain size can be performed if needed (polishing + SEM or FIB), more in background slides.
- Thermal treatments to increase grain size could be investigated, above Mo recrystallization temperature (900-1300°C [1]). Problems: coating detachment, Mo+C→carbide, gas influence during treatment [2].

[1] On the Recrystallization Behavior of Technically Pure Molybdenum, S. Primig et al. 17th Plansee Seminar 2009, Vol. 1

https://www.plansee-com.azureedge.net/fileadmin/user_upload/On_the_Recrystallization_Behavior_of_Technically_Pure_Molybdenum_2009.pdf

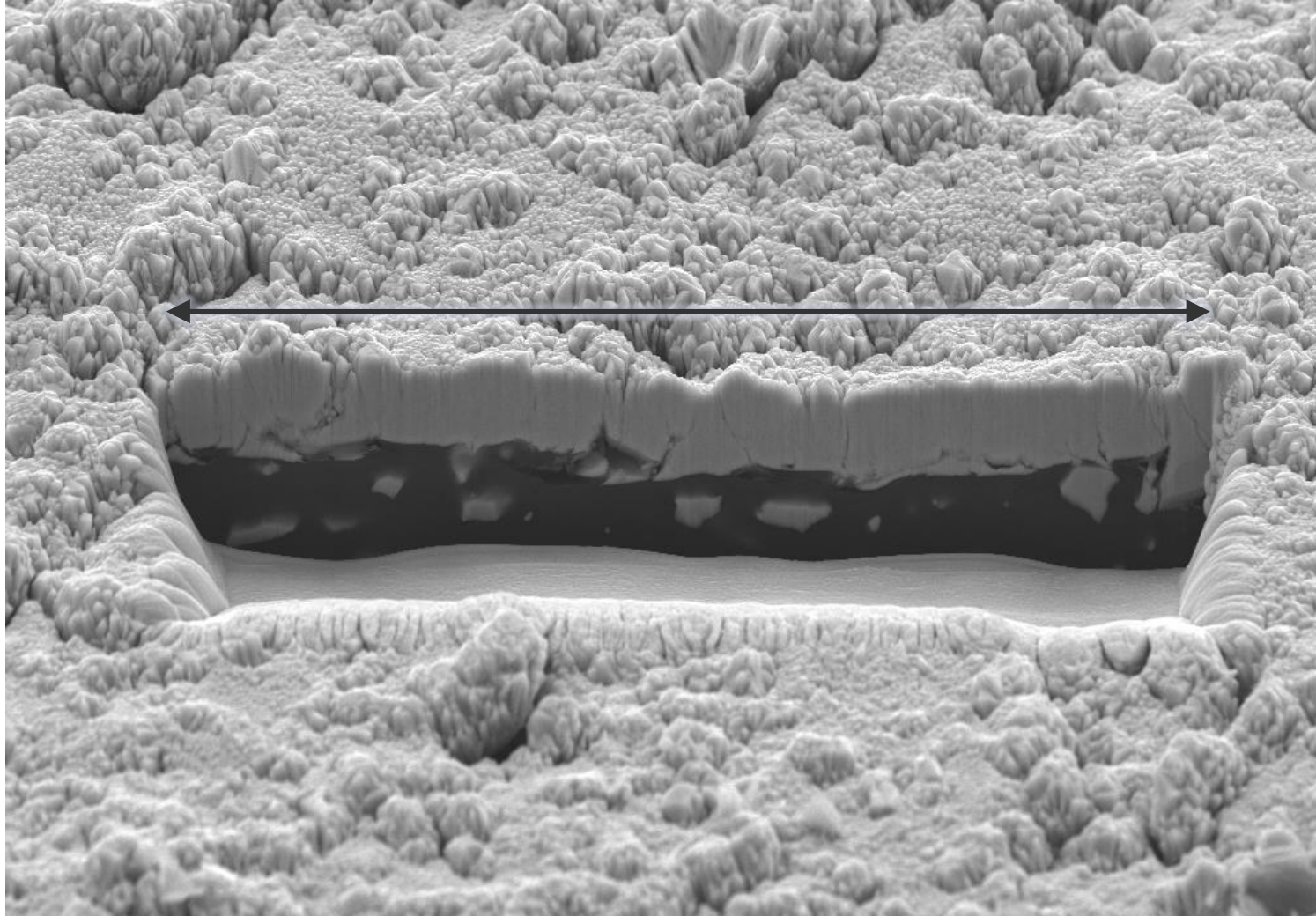
[2] Effect of inert gases on the recrystallization of tungsten Yu M. Aleksandrova et al. Fiziko-Khimicheskaya Mekhanika Materialov, Vol 2, No 3, pp. 327-332, 1966.

<https://link.springer.com/content/pdf/10.1007%2FBF00714677.pdf>



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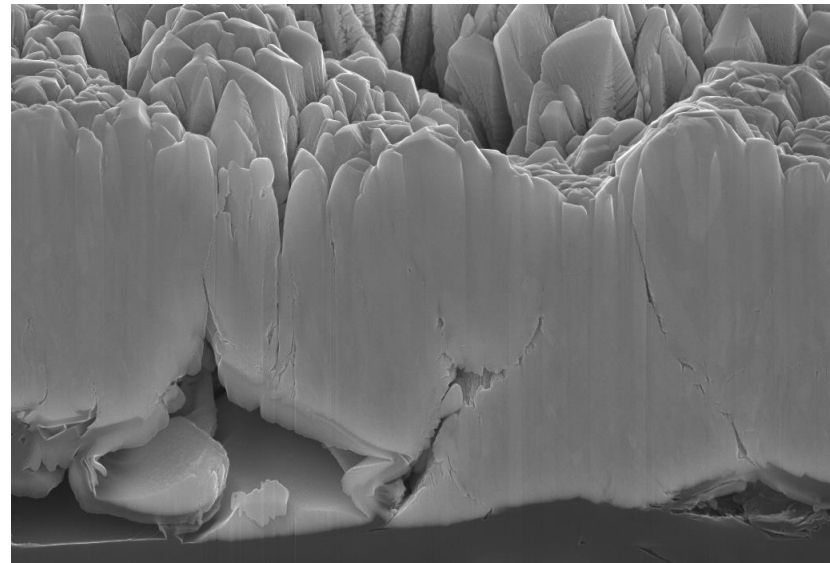
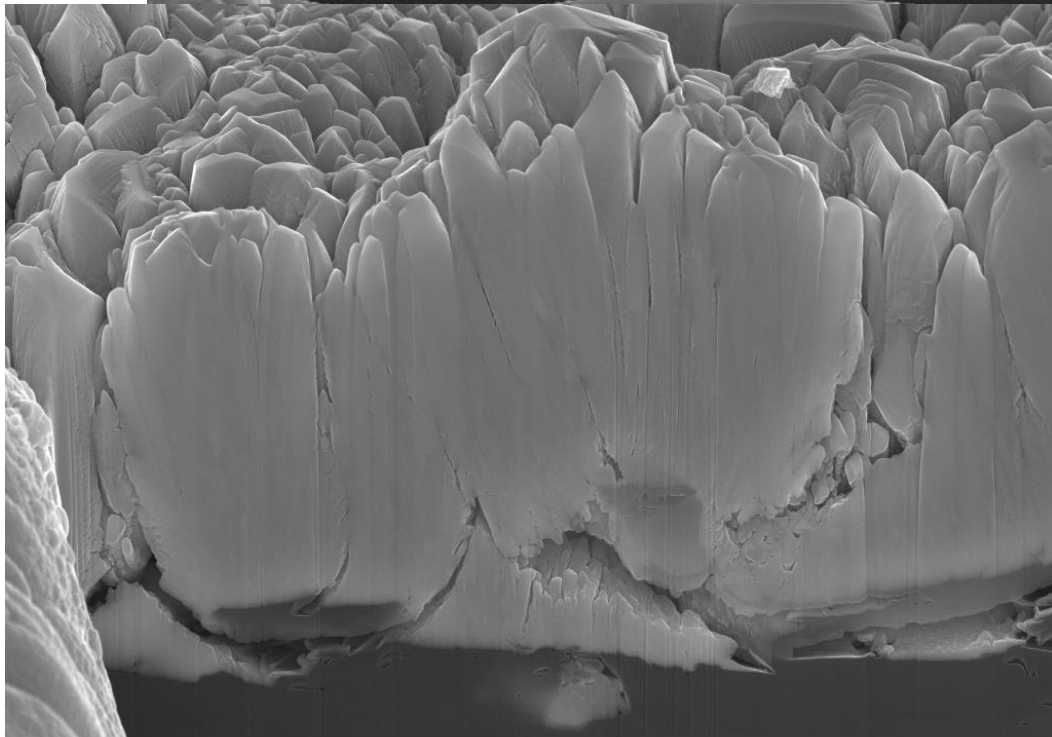
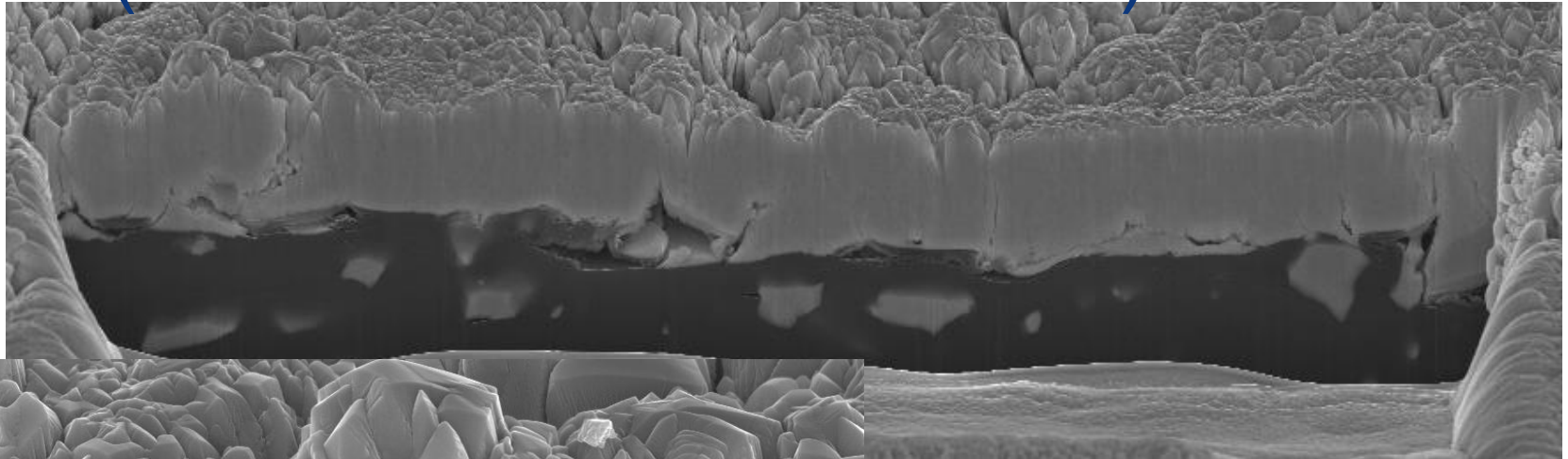
FIB (Mo on MoGr NB-8304Je)



local study:
~60 μ m

10 μ m ESB Grid = 0 V I Probe = 1.1 nA WD = 5.0 mm Detector = SEI 14 Dec 2017 Alexander Lunt EN CERN
EHT = 20.00 kV Mag = 1.28 K X 8:54:25

FIB (Mo on MoGr NB-8304Je)



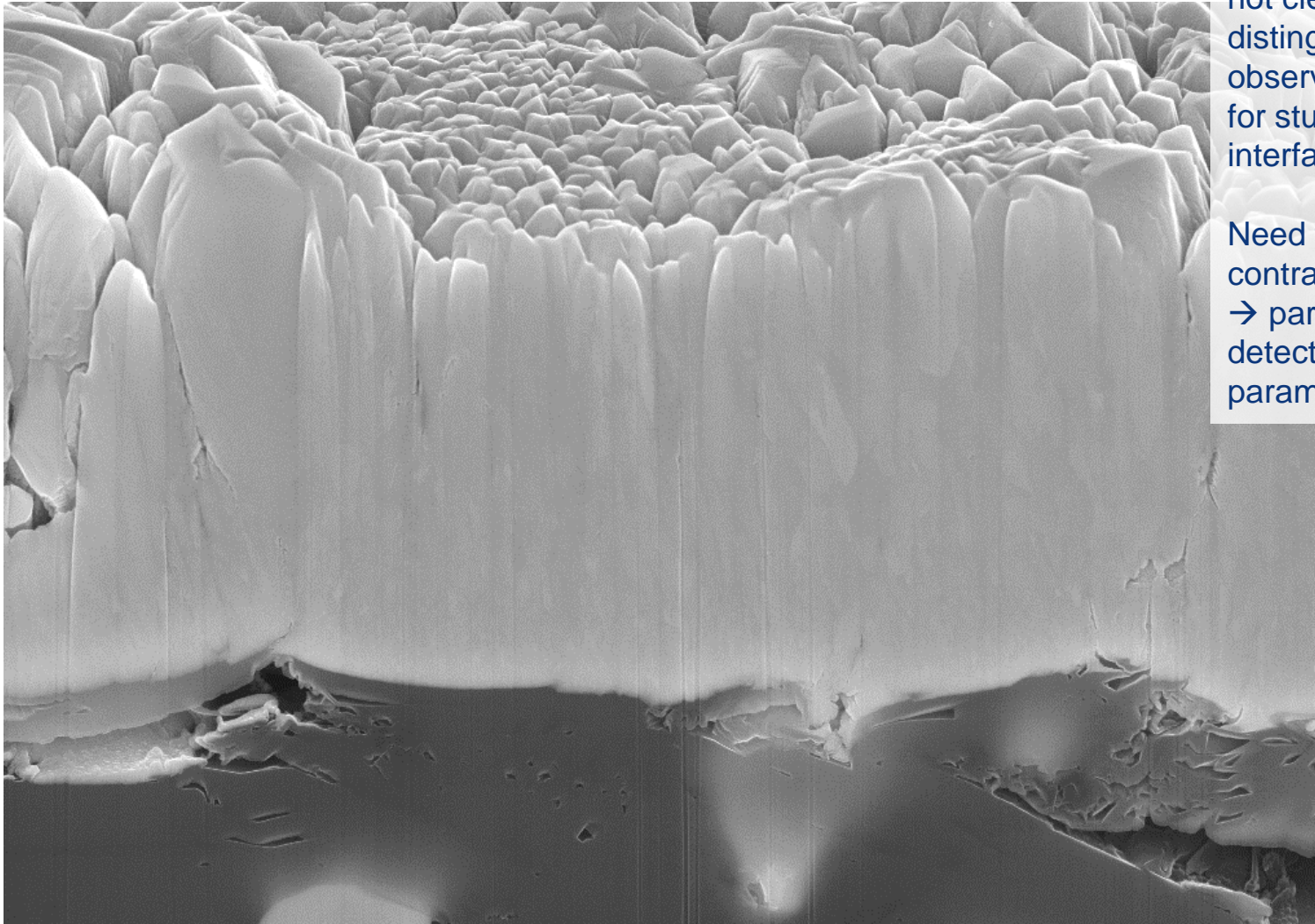
2 μm ESB Grid = 0 V IProbe = 1.1 nA WD = 5.0 mm Detector = InLens 14 Dec 2017 Alexander Lunt CERN
EHT = 20.00 kV Mag = 7.56 K X 9:11:39

2 μm ESB Grid = 0 V IProbe = 1.1 nA WD = 5.0 mm Detector = InLens 14 Dec 2017 Alexander Lunt CERN
EHT = 20.00 kV Mag = 7.56 K X 9:09:32

FIB (Mo on MoGr NB-8304Je)

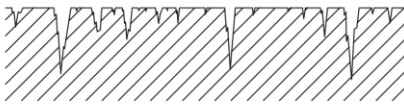
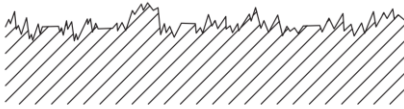
In this case, grains are not clearly distinguishable (these observations were done for studying the interface)

Need to improve contrast between grains
→ particular SEM detector/ beam parameters

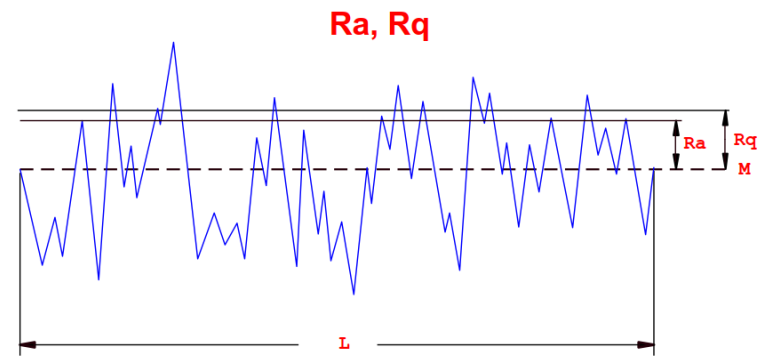


2 μm ESB Grid = 0 V I Probe = 1.1 nA WD = 5.0 mm Detector = InLens 14 Dec 2017 Alexander Lunt
EHT = 20.00 kV Mag = 7.56 K X 9:09:59 CERN

Roughness definitions

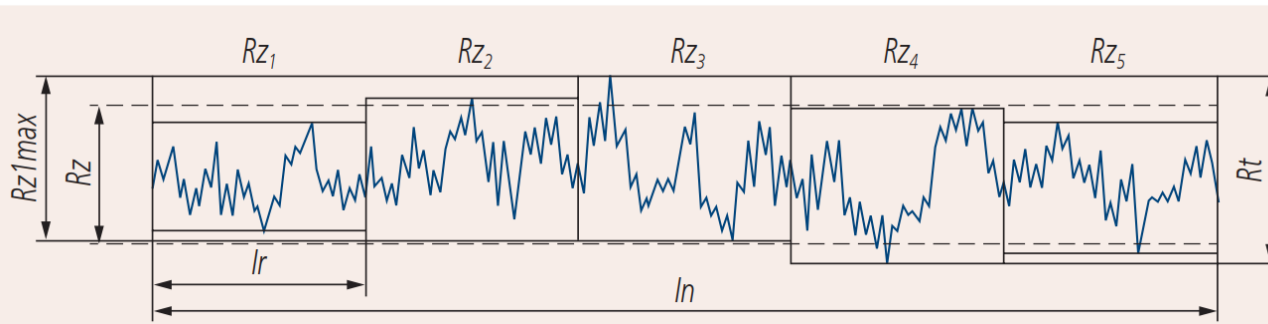
Surface Profile	R_a
	0.2
	0.2

Even with identical R_a values, the performance of the surface may be very different



Roughness Average, R_a , is the arithmetic average of the absolute values of the profile heights over the evaluation length.

RMS Roughness, R_q , is the root mean square average of the profile heights over the evaluation length

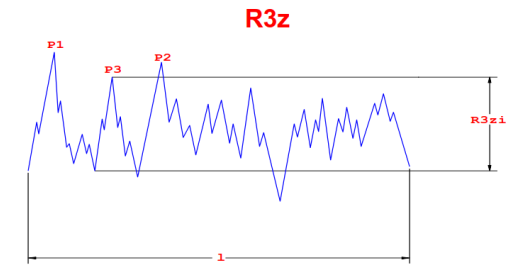


R_t – total height of the roughness profile: Difference between height Z_p of the highest peak and depth Z_v of the deepest valley within the evaluation length l_n (Figure 7).

Rz_i – greatest height of the roughness profile: Sum of the height of the highest profile peak and the depth of the deepest profile valley, relative to the mean line, within a sampling length l_{r_i} .

Rz_{1max} – maximum roughness depth: Largest of the five Rz_i values from the five sampling lengths l_{r_i} within the evaluation length l_n .

Rz – mean roughness depth: Mean value of the five Rz_i values from the five sampling lengths l_{r_i} within the evaluation length l_n .



Third Maximum Peak-to-Valley Height, R_{3z} , is the mean of the third maximum peak-to-valley heights in the evaluation length.

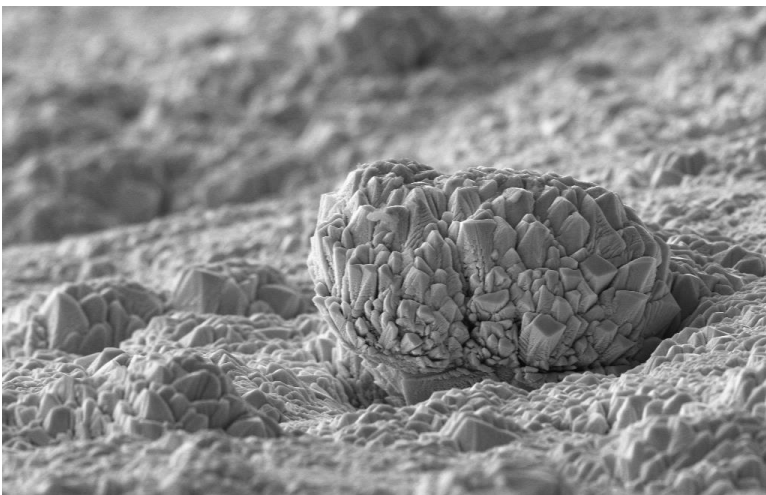
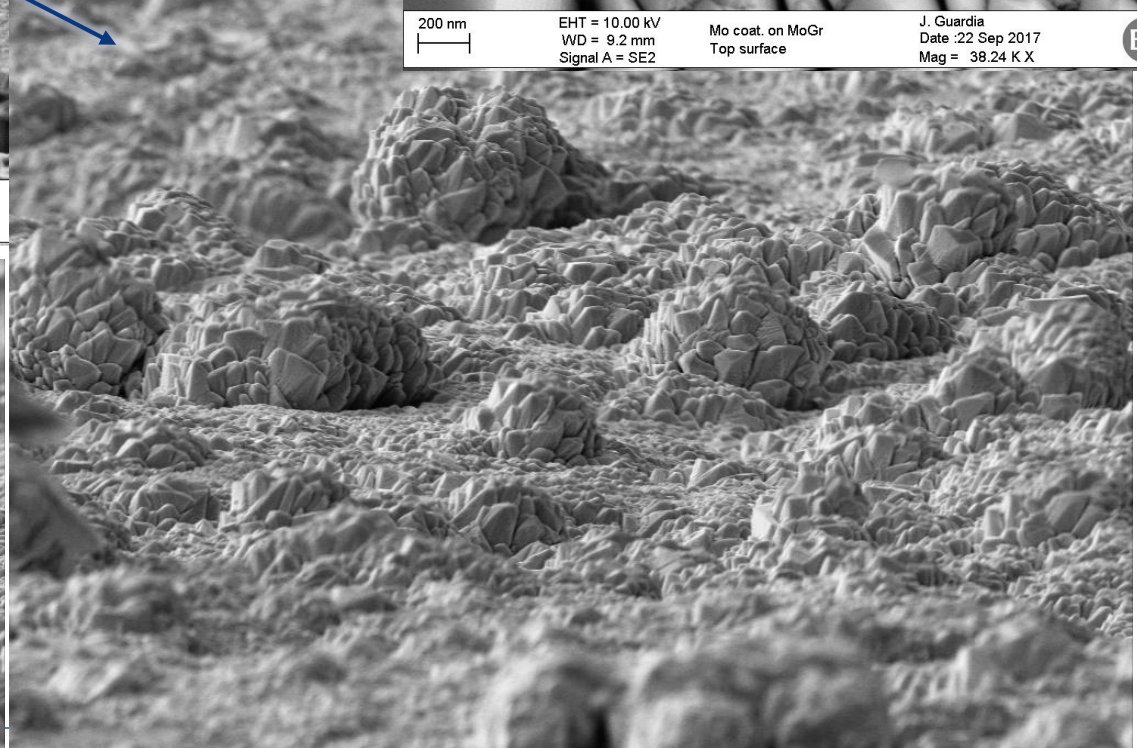
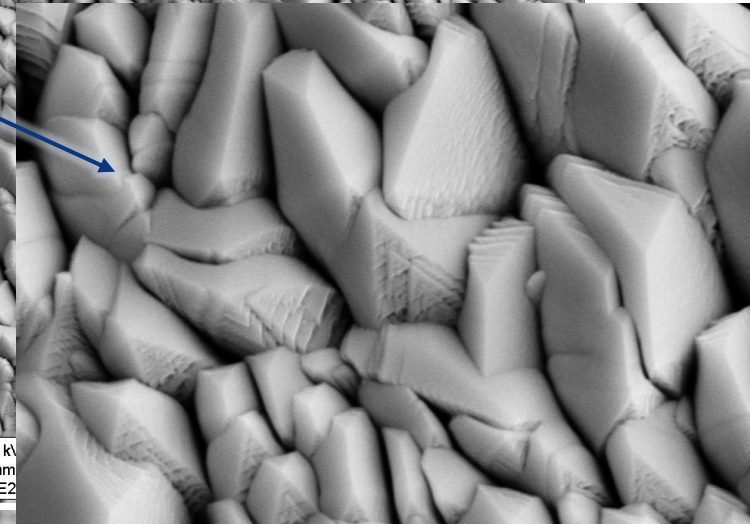
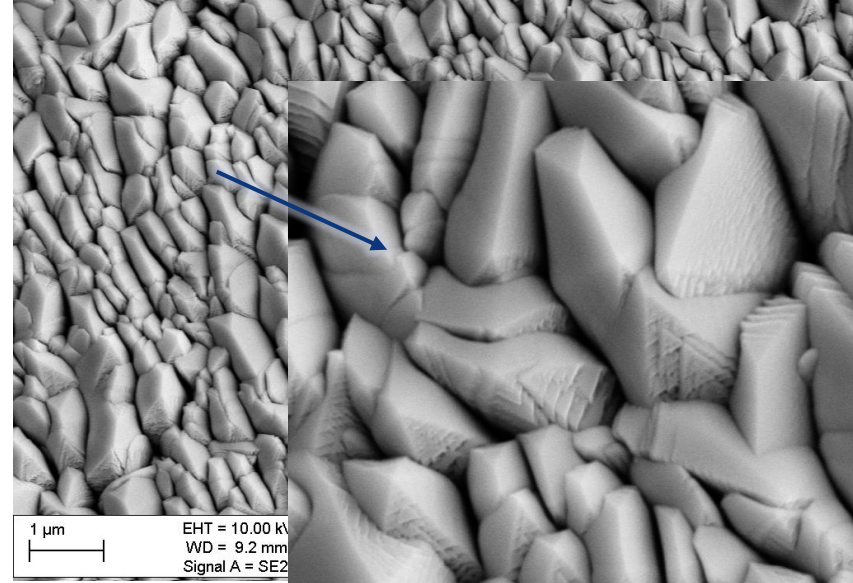
Refs: Mituyoyo Quick guide to roughness measurement Bulletin No. 2229 (2016)
https://www.mitutoyo.com/wp-content/uploads/2012/11/1984_Surf_Roughness_PG.pdf

http://www.predev.com/pdf/files/surface_roughness_terminology_and_parameters.pdf

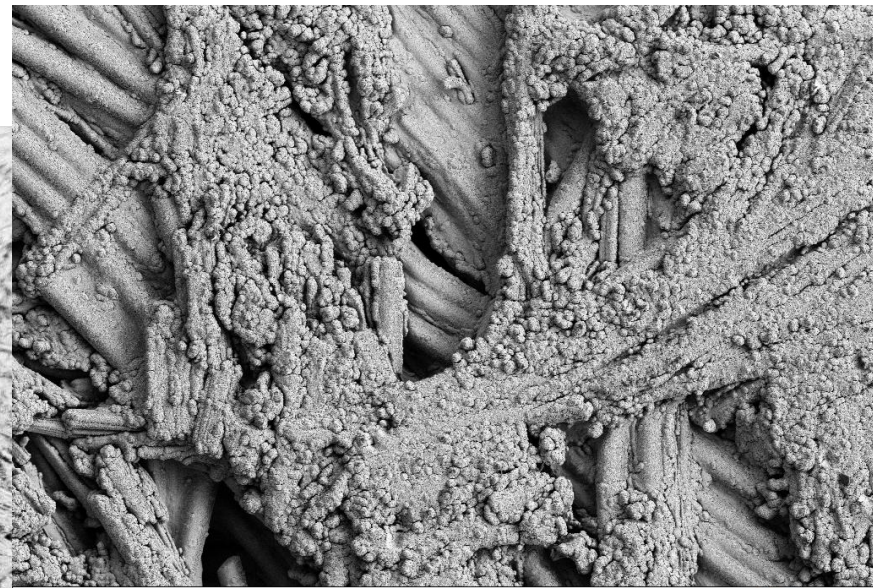
https://www.tss-static.com/remotemedia/media/globalformastercontent/products/staticseals/airseal/files/aerospace_gb.pdf

Observations shown in past meetings

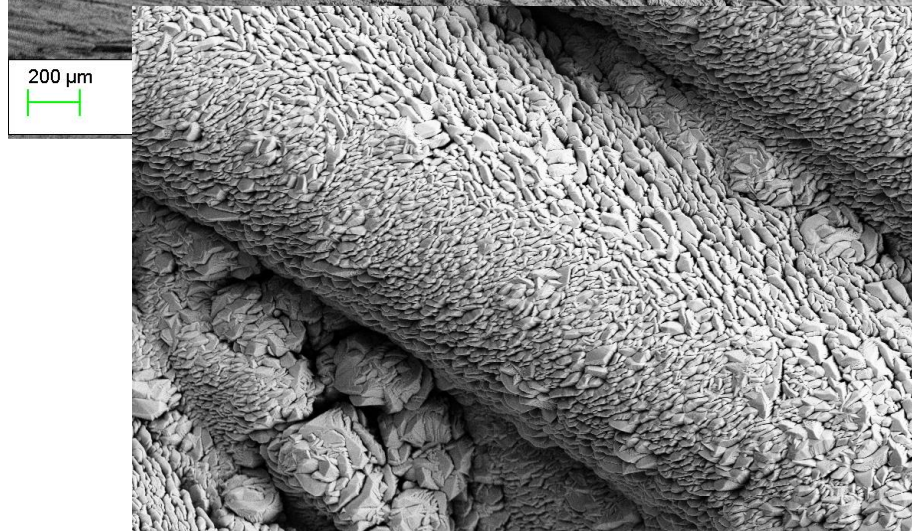
Mo on MoGr



Mo on CFC FS140

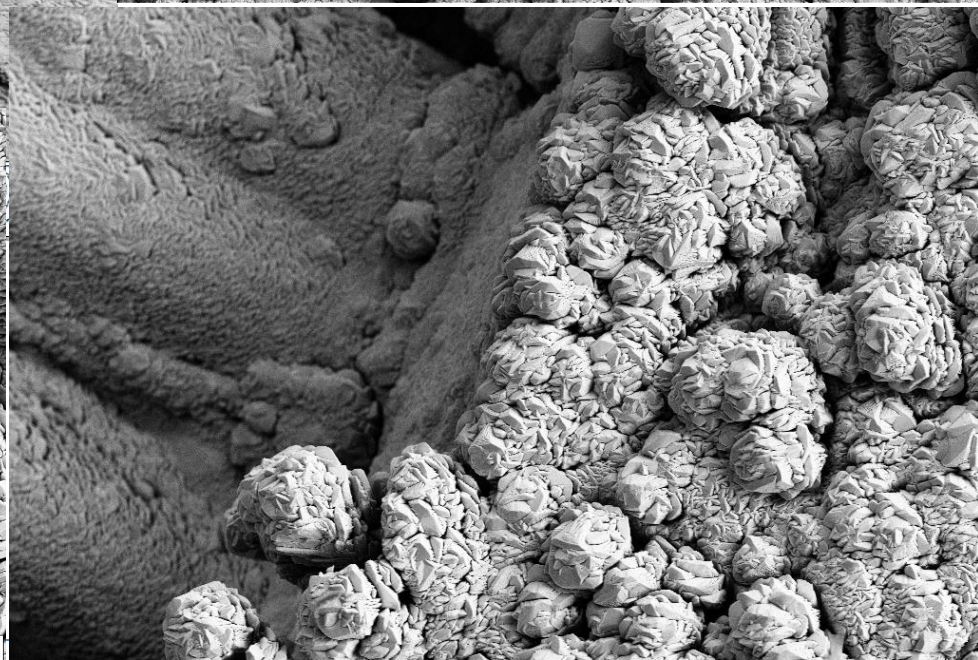


20 μm EHT = 5.00 kV
WD = 5.9 mm Mo coating on CFC Jorge Guardia
Date :13 Apr 2018
Signal A = SE2 Mag = 250 X

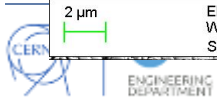


200 μm

2 μm EHT = 5.00 kV
WD = 5.9 mm Mo coating on CFC Jorge Guardia
Date :13 Apr 2018
Signal A = SE2 Mag = 3.00 K X



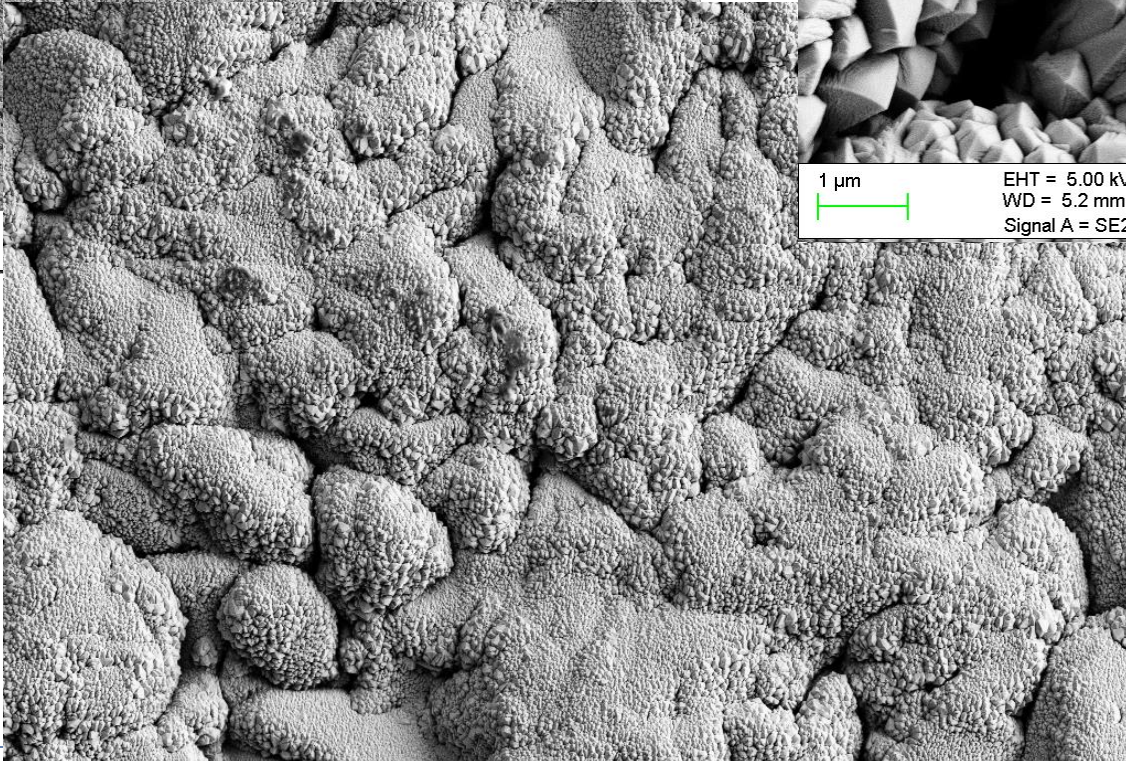
2 μm EHT = 5.00 kV
WD = 5.9 mm Mo coating on CFC Jorge Guardia
Date :13 Apr 2018
Signal A = SE2 Mag = 2.00 K X



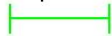
Mo on Al₂O₃



100 μm



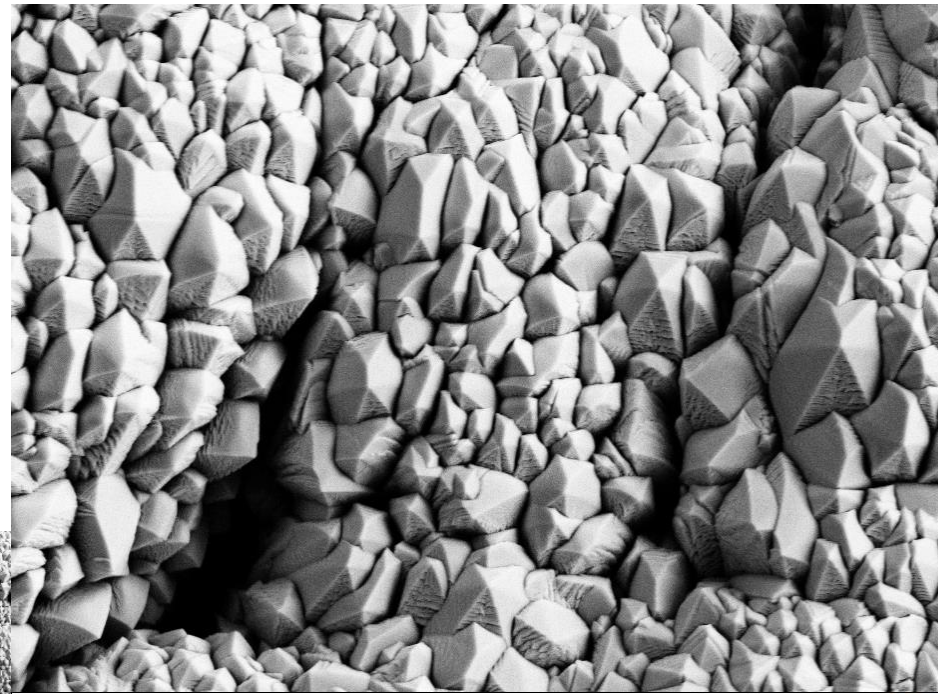
10 μm



EHT = 5.00 kV
WD = 5.2 mm
Signal A = SE2

Mo coating on Al₂O₃

Jorge Guardia
Date :13 Apr 2018
Mag = 1.00 K X



1 μm



EHT = 5.00 kV
WD = 5.2 mm
Signal A = SE2

Mo coating on Al₂O₃

Jorge Guardia
Date :13 Apr 2018
Mag = 10.00 K X

